

Appl. No. 10/643,115
Examiner: NGUYEN, DILINH P, Art Unit 2814
In response to the Office Action dated March 24, 2006

Date: May 18, 2006
Attorney Docket No. 10112761

REMARKS

Responsive to the Office Action mailed on March 24, 2006 in the above-referenced application, Applicant respectfully requests amendment of the above-identified application in the manner identified above and that the patent be granted in view of the arguments presented. No new matter has been added by this amendment.

Present Status of Application

Claims 1-7, 9, 10 and 21 remain in the application. The specification and claims are objected to for informalities. Prosecution on the merits is closed in accordance with the practice under *Ex parte Quayle*.

In this paper, the specification and claims are amended according to the suggestion of the Examiner and to correct other informalities. In particular, claim 1 is amended to recite "removing the interval layer to expose a sidewall of a portion of the trench which is uncovered by the sacrificial layer and the conductive layer" in accordance with the suggestions of the Examiner and to further clarify the step. Support for the amendment can be found in Fig. 3F of the application. In light of this amendment, it is not considered necessary to add "remaining" on line 13 of the claim as suggested by the Examiner.

It is therefore Applicant's belief that the application is now in condition for allowance and that action is earnestly solicited.

Respectfully submitted,



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